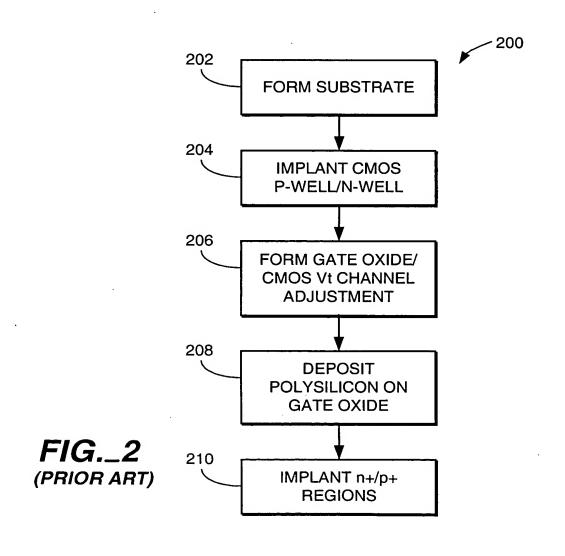
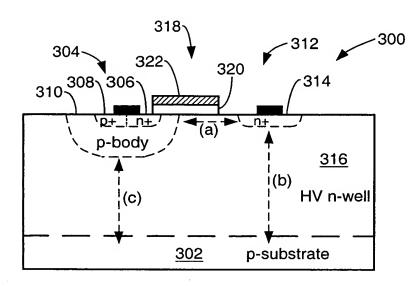


FIG.\_1 (PRIOR ART)



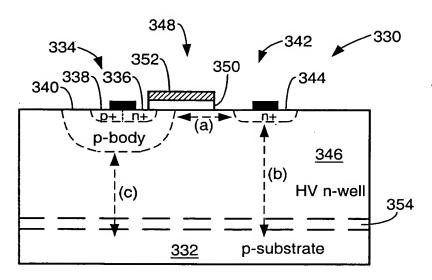
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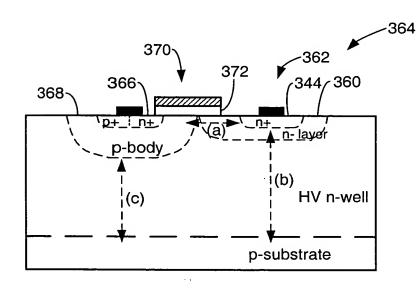
P-Body implanted after gate formation disrupts CMOS thermal budget

FIG.\_3A (PRIOR ART)



P-Body implanted after gate formation disrupts CMOS thermal budget

> FIG.\_3B (PRIOR ART)



P-Body implanted after gate formation disrupts CMOS thermal budget

> FIG.\_3C (PRIOR ART)

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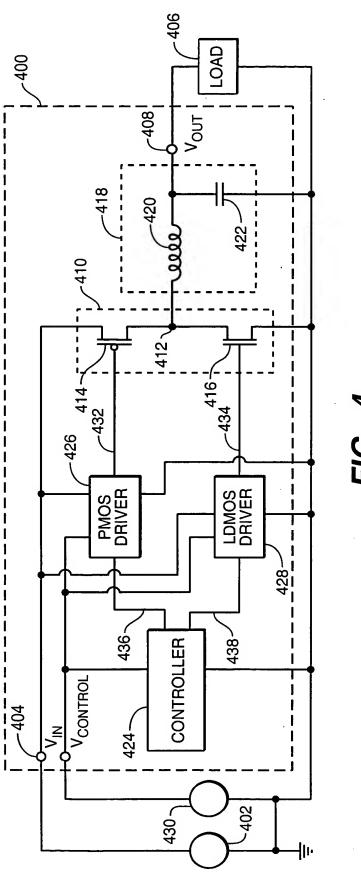


FIG.\_4

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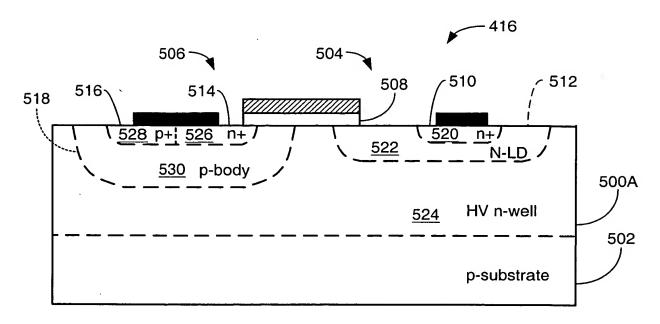


FIG.\_5A

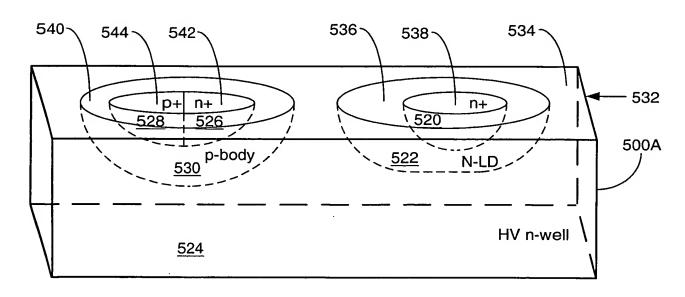
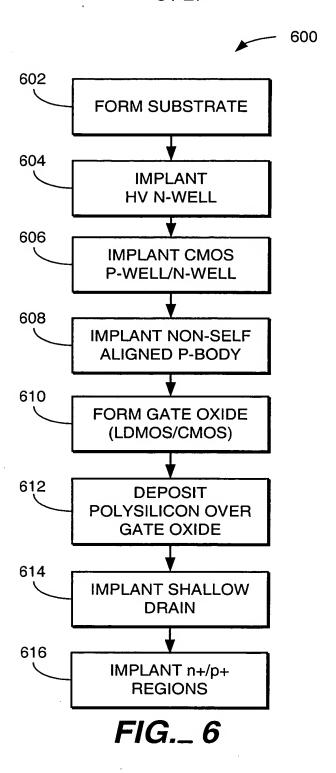
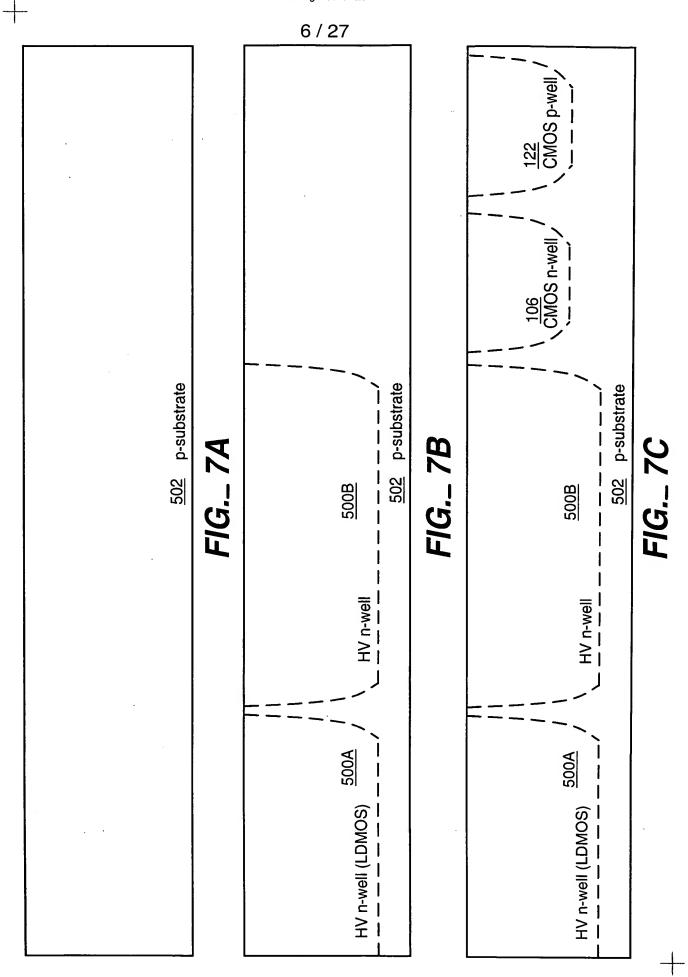
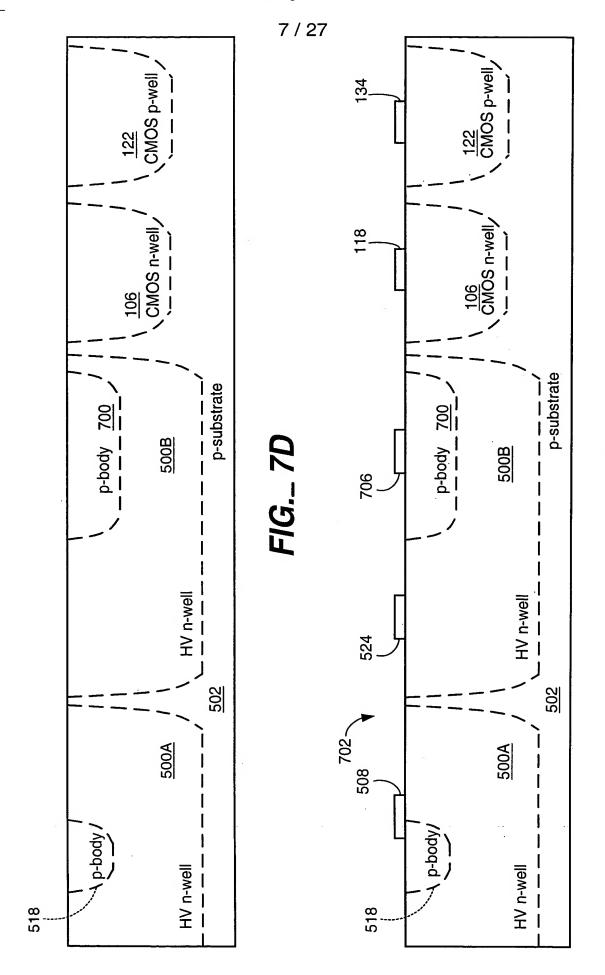


FIG.\_5B

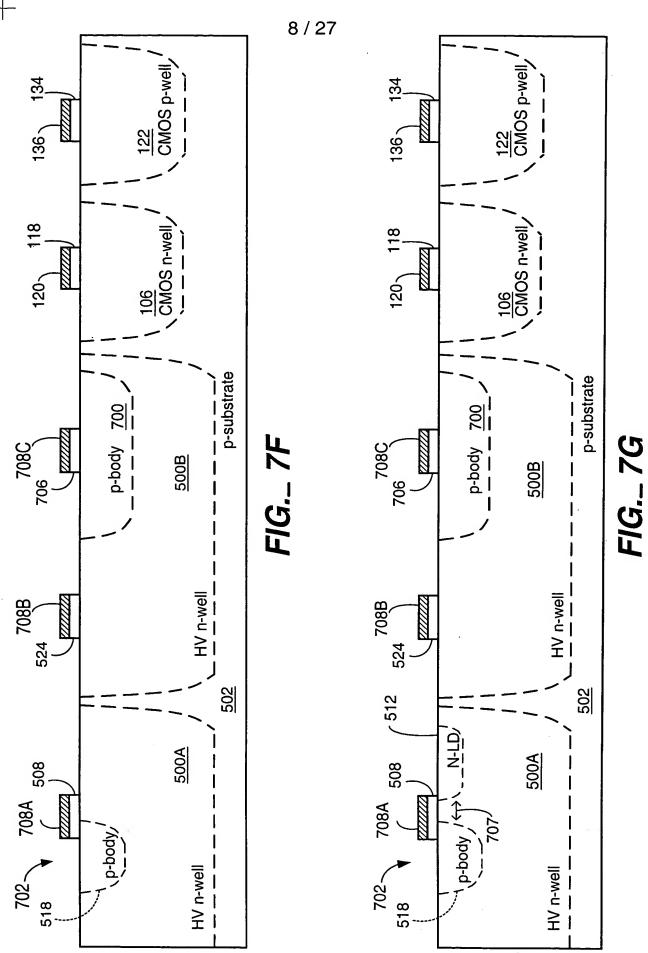
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-1G.\_ 7E





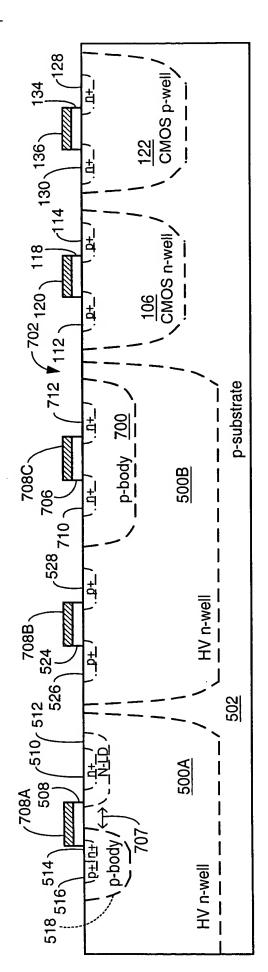
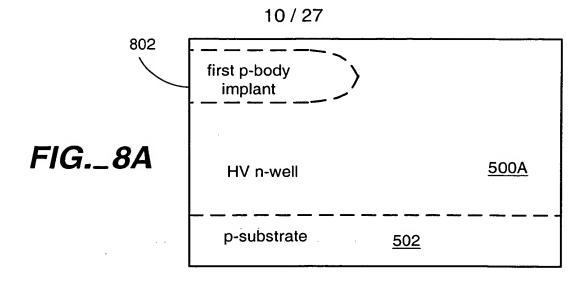
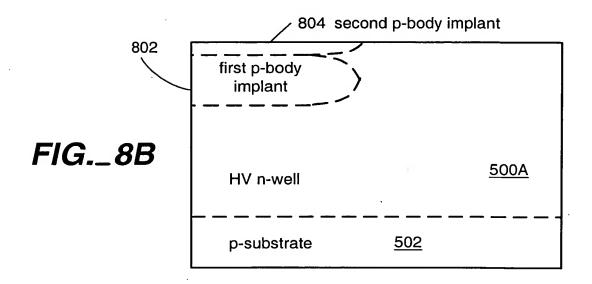
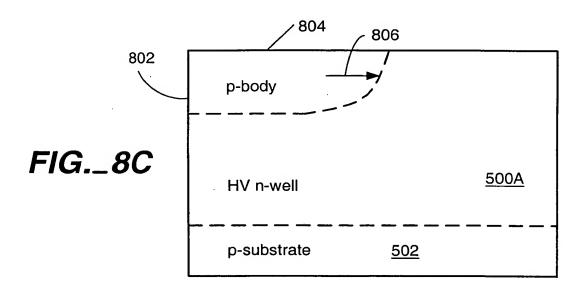


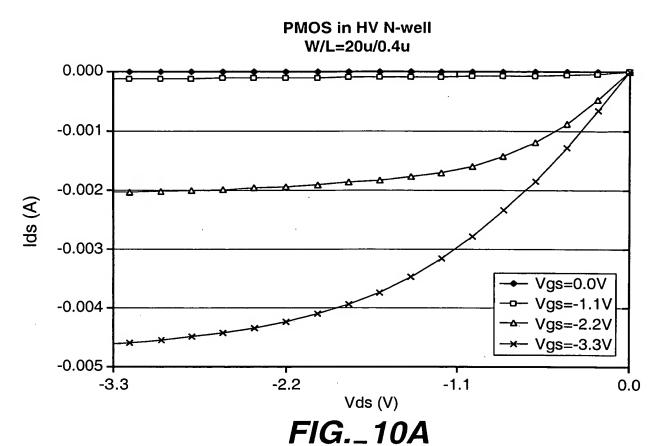
FIG. 9







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PMOS in Regular N-well

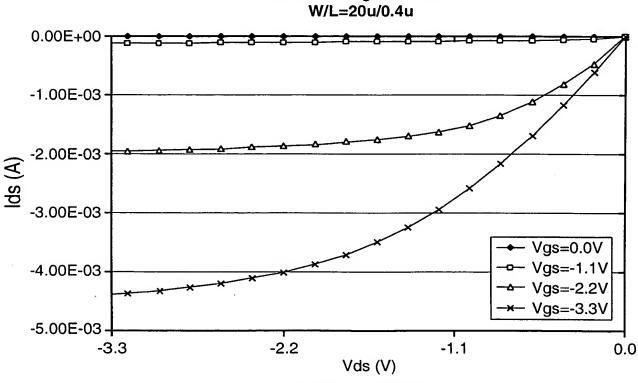
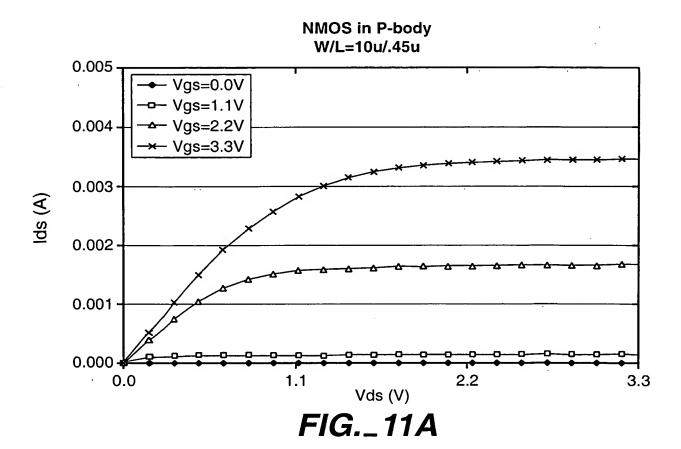
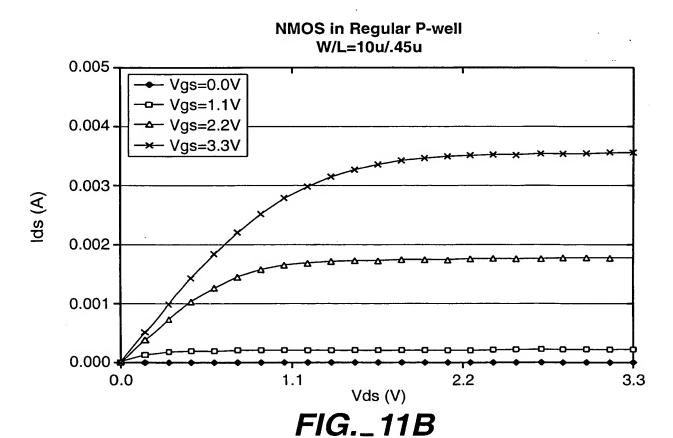


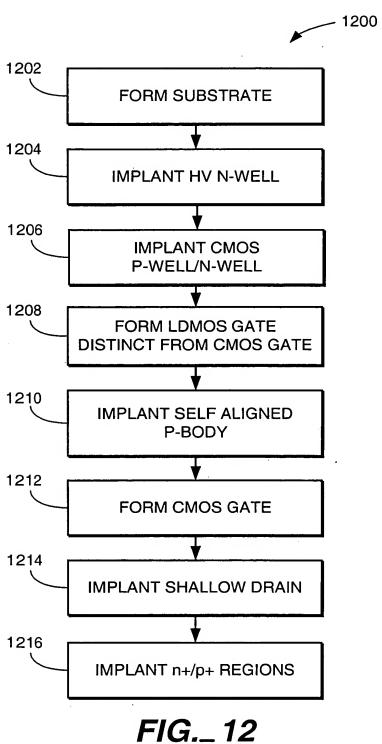
FIG.\_10B

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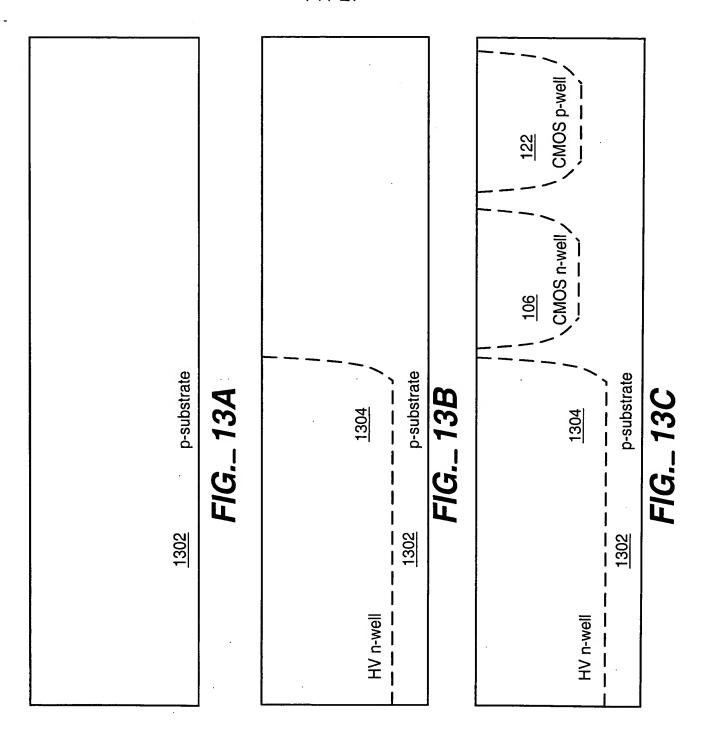




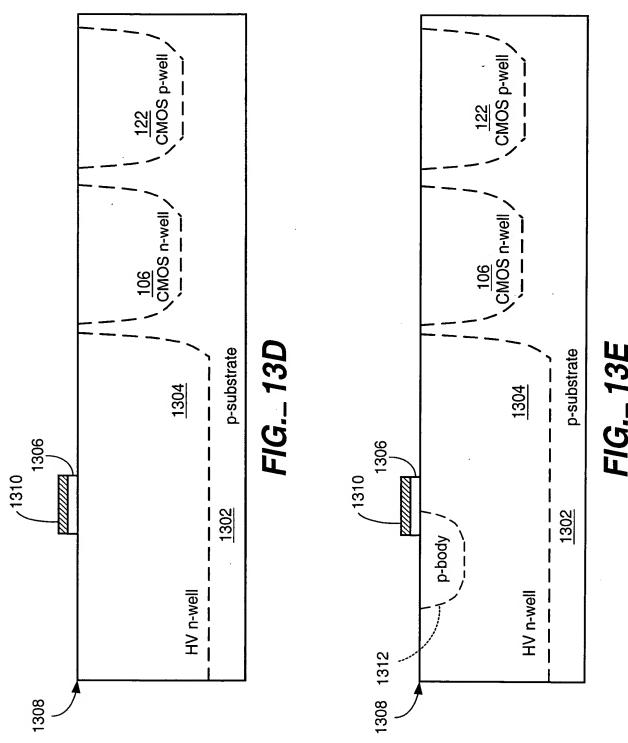
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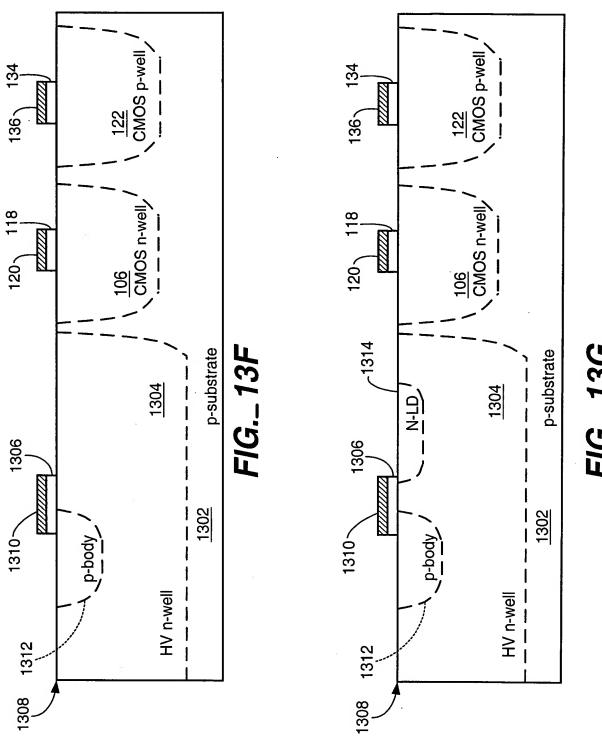


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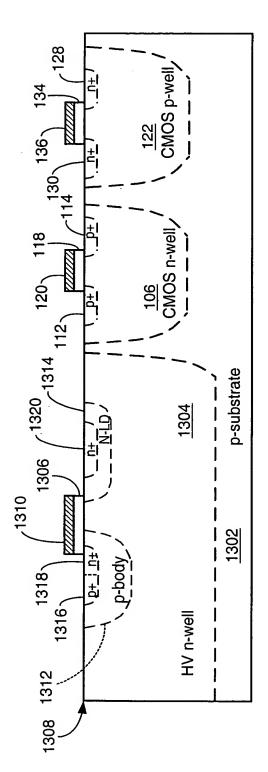


FIG.\_ 13H

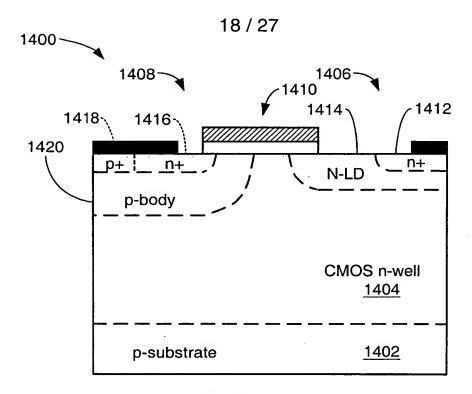


FIG.\_ 14

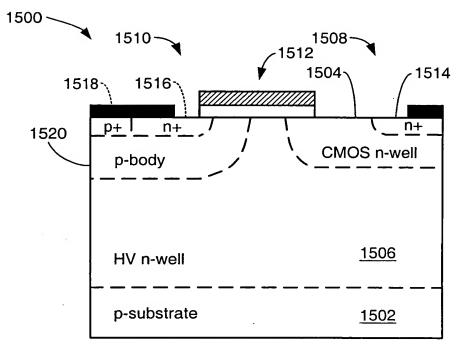


FIG.\_15

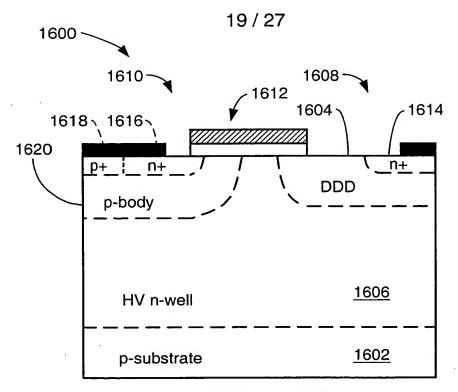


FIG.\_ 16

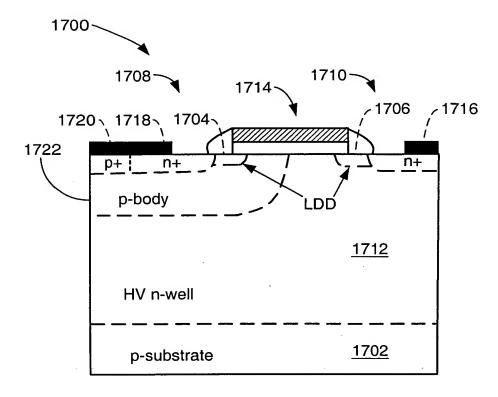


FIG.\_17

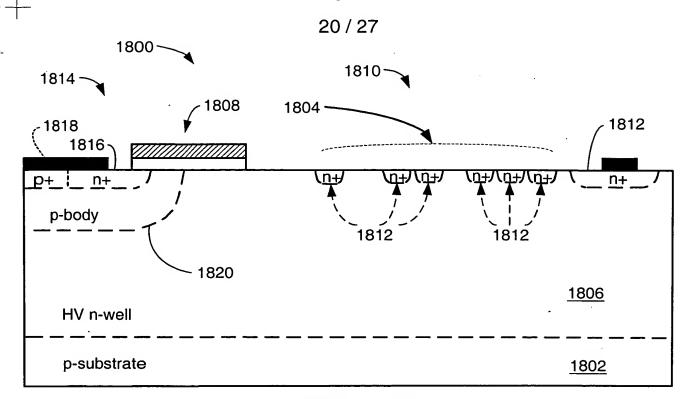


FIG.\_ 18

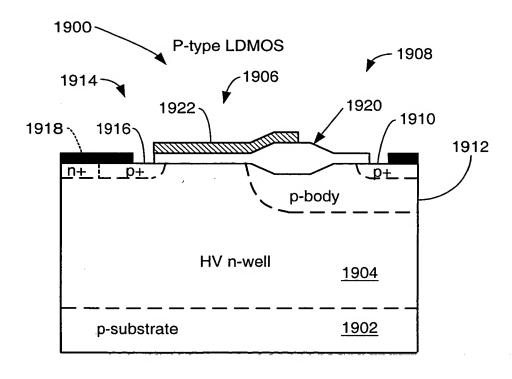


FIG.\_19

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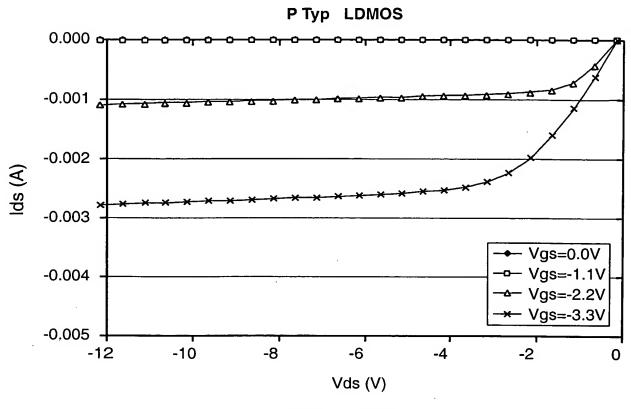


FIG.\_20

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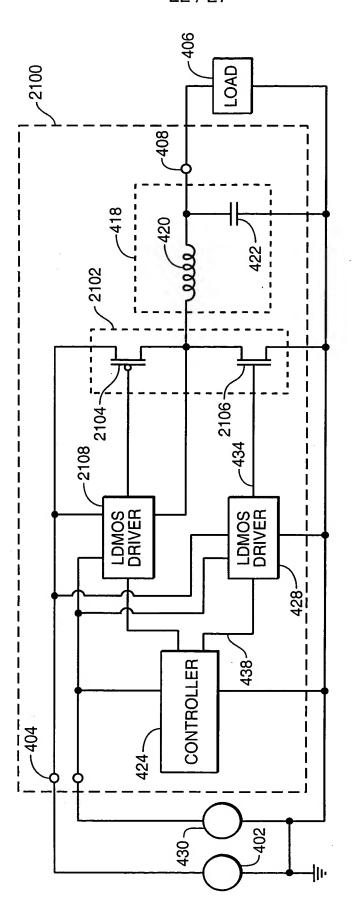
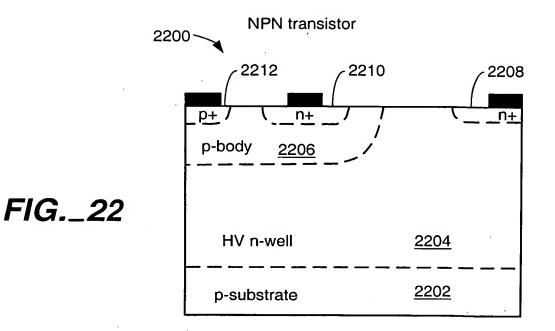
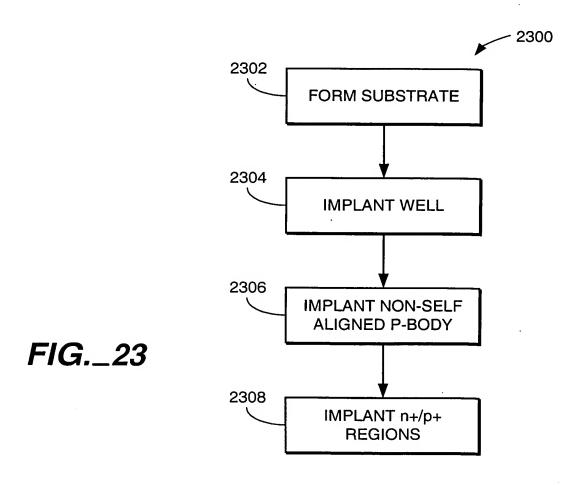


FIG.\_21

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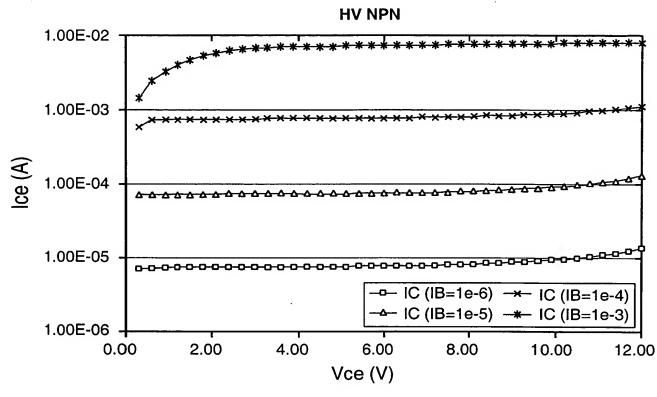
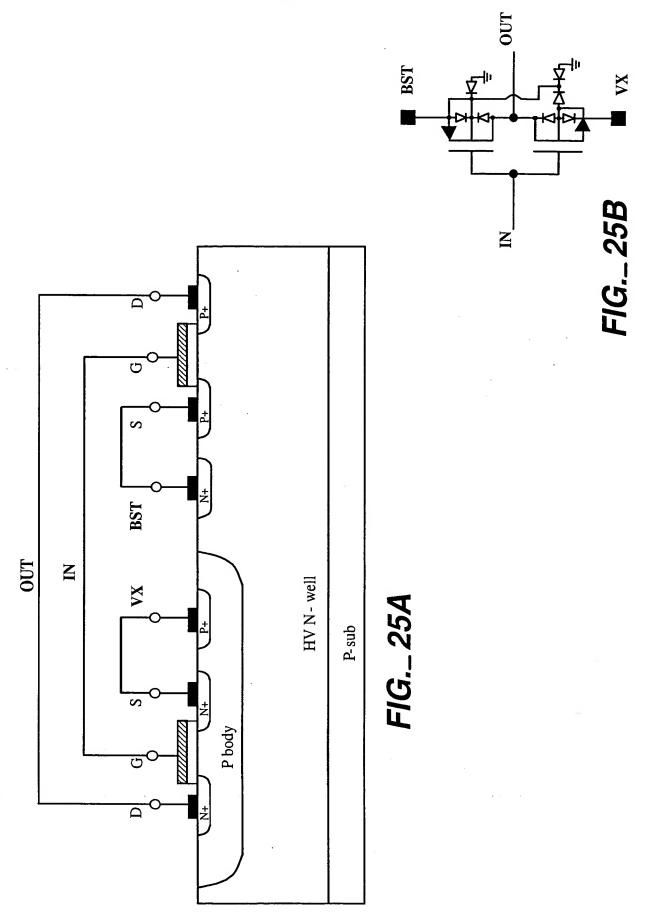


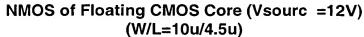
FIG.\_24

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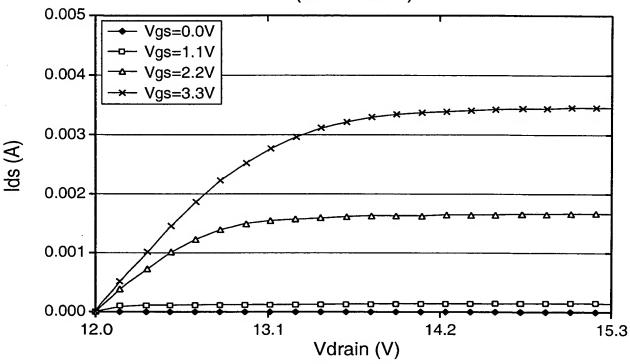
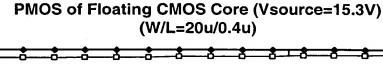


FIG.\_26A



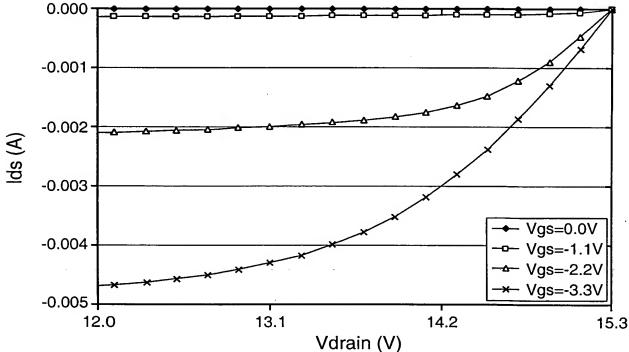


FIG.\_26B

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